

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Watanabe et al.
Appl. No. : 10/574,073
Filed : March 30, 2006
For : RESIST COMPOSITION FOR
ELECTRON BEAM OR EUV
Examiner : Walke, Amanda
Group Art Unit : 1752

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **June 21, 2007**, please amend the above-referenced application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.